

Docket No.: IPA-006

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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|------------------------------------|---|-----------------------|
| In re Application of | : | |
| | : | Confirmation No. |
| Akira NAKASHIMA et al. | : | |
| | : | |
| U.S. Patent Application No.: ----- | : | Group Art Unit: ----- |
| | : | |
| Filed: <i>herewith</i> | : | |

For: METHOD OF FORMING AMORPHOUS SILICA-BASED COATING FILM WITH
LOW DIELECTRIC CONSTANT AND THUS OBTAINED SILICA-BASED
COATING FILM

PRELIMINARY AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

Preliminary to examination of the above-referenced application, please amend the application as follows:

AMENDMENTS TO THE SPECIFICATION

AMENDMENTS TO THE CLAIMS:

REMARKS